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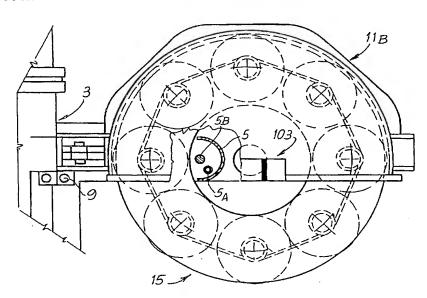
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(54) Title: PLANT FOR VACUUM COATING OF OBJECTS TREATED IN BATCHES



(57) Abstract: A plant for vacuum metallization of objects treated in batches is described, said plant comprising: a vacuum chamber; at least one carousel (15) which rotates about an axis of rotation (A-A) and which is arranged inside said vacuum chamber when the plant is in operation; at least one discharge electrode (5B); at least one diffuser (5A) associated with said discharge electrode for introduction of at least one protective substance for metallization. The discharge electrode (5B) and the diffuser (5A) are associated with a housing arranged inside said vacuum chamber, in an approximately central position, said housing enclosing at least partly said diffuser and said electrode.